



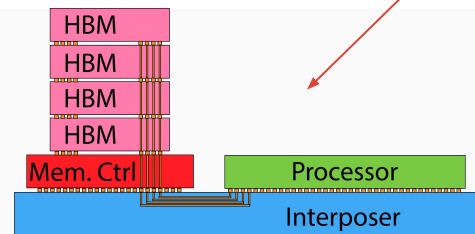
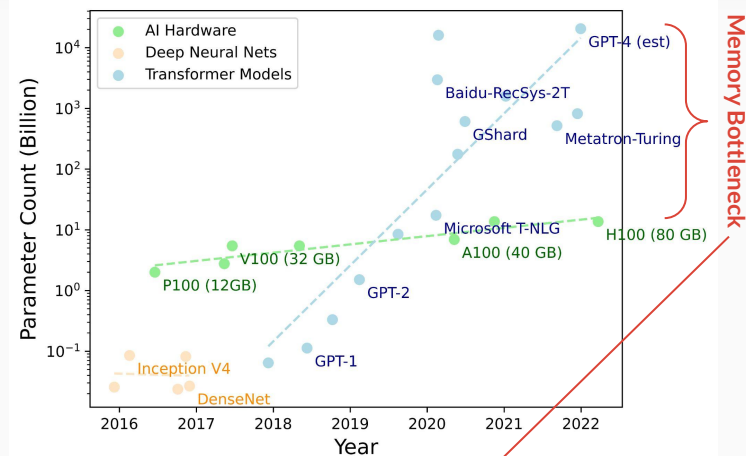
# NTessimal

Bottom-up Nanofabrication Tools

# AI Compute Demands Outpace Hardware Development

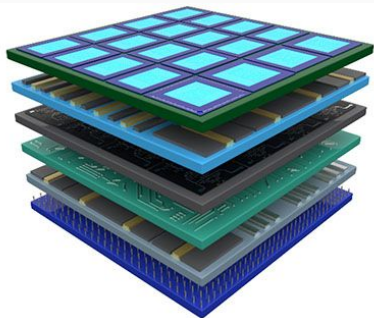
- ❑ Larger AI models offer significant potential to revolutionize most economic sectors
- ❑ Current hardware approaches have struggled to keep pace with mathematical advances
  - ❑ Increasing die size
  - ❑ Increasing integration with packaging
  - ❑ Fine tuning architecture

A **faster rate** of hardware improvement is necessary



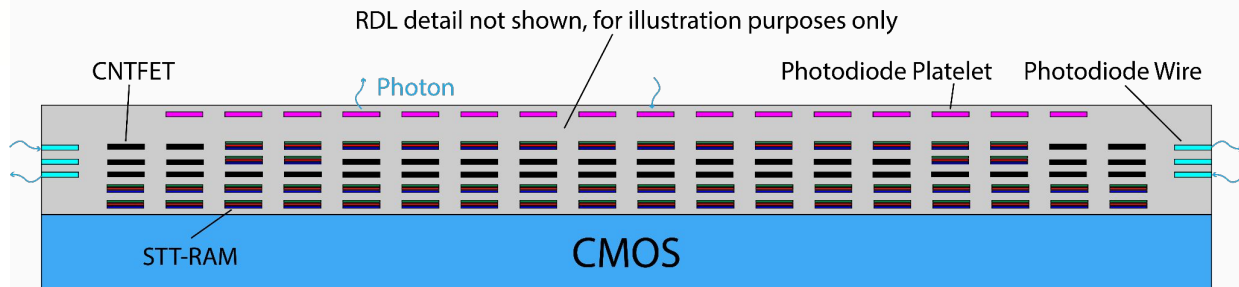
# Bottom-Up Integration for 3DHI-VLSI

## 3DHI ( $\mu$ Scale)



(DARPA rendering, 2023)

## 3DHI-VLSI (nanoscale)

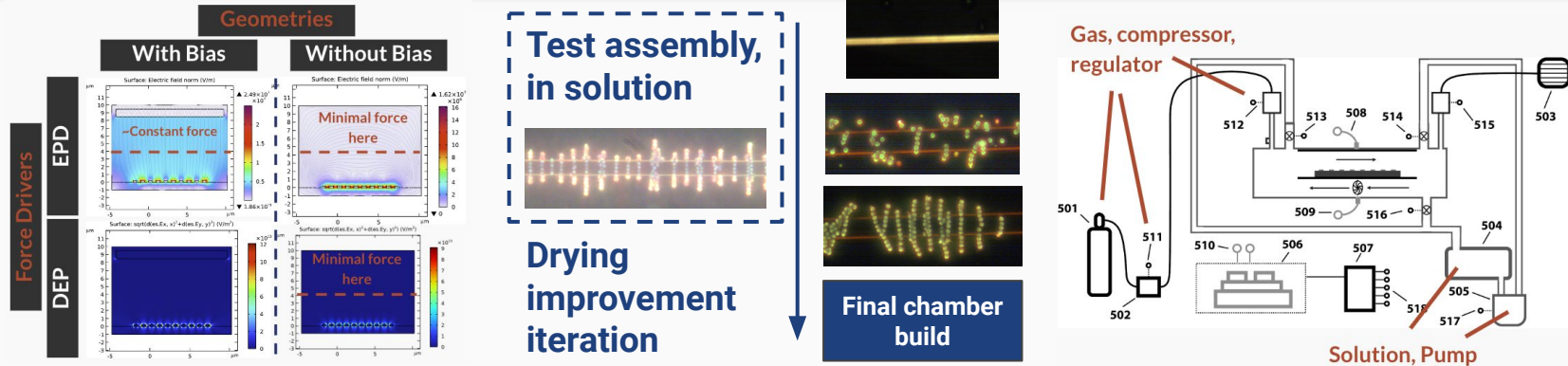


Conceptual drawing

- ❑ Nanoscale high density interconnects
- ❑ Larger materials set, fabricated off substrate
- ❑ Multi-functional die - logic, memory, optical
- ❑ True 3D topology

Lithography defined integration allows  
for a potential  **$\geq 1,000\times$  improvement** over  
traditional packaging

# Multi-Physics Nanoparticle Assembly



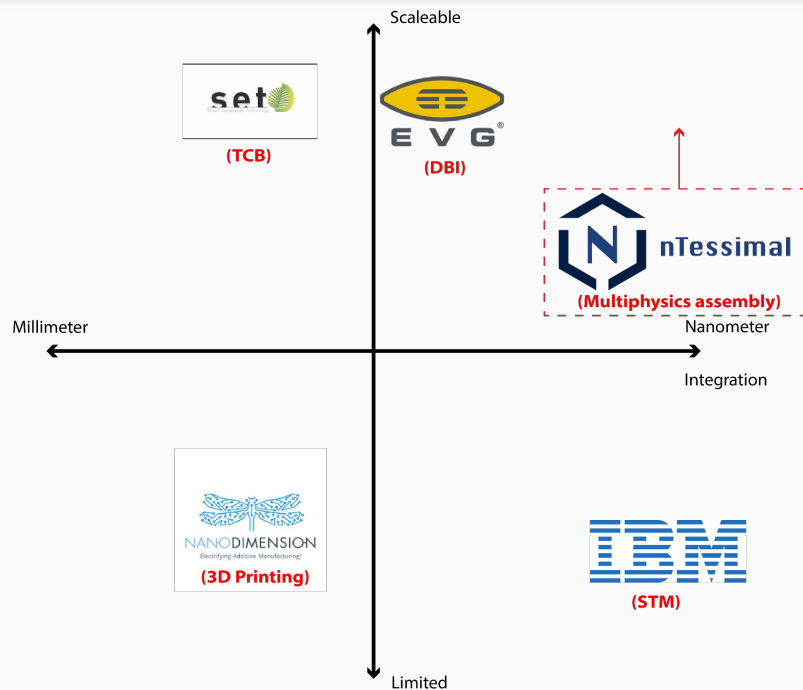
- ❑ nTessimal's patent pending chamber for assembly of nano-particles/wires/platelets
  - ❑ Replaces microfluidics with DC electric field forces to decrease contamination and allow throughput required for manufacturing
  - ❑ Utilizes supercritical drying maintains yield
  - ❑ Packaged with process expertise

Full wafer patterning,  
reduced surface tension

# Competitive Landscape

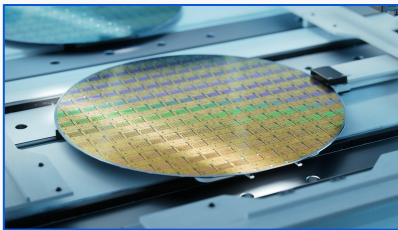
- ❑ Our technology will enable the tightest integration level and has the potential for the greatest performance improvement
- ❑ We are not directly competing with any option listed here as *all levels of integration should be leveraged*
  - ❑ Direct bond interconnects
  - ❑ Thermocompression bonding
  - ❑ Printed circuit boards

We offer the unique potential for  
scaleable nanoscale 3D integration





# Traction & Additional Applications



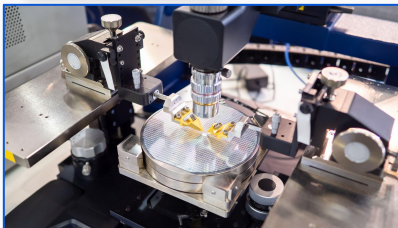
## Pure Play Semiconductor Foundries

We recieved a NSF grant support letter from a semiconductor foundry who understands the value of patterning high purity CNFETs



## Biotechnology

We recieved a NSF grant support letter from a company to increase manufacturability of microparticle based monitoring antenna and lab-on-chip solutions



## Advanced Substrates

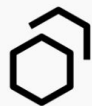
We're working with a glass substrate manufacturer on high aspect ratio via fill including novel materials

# Learn more about how nanoparticle assembly technology can help you!

- ❑ Website: <https://ntessimal.com/>
- ❑ LinkedIn: <https://www.linkedin.com/company/ntessimal/>
- ❑ PI Email: [Steve.Snyder@nTessimal.com](mailto:Steve.Snyder@nTessimal.com)

## Compute

3D Logic  
Compute Near /  
In Memory  
uTopology 3DHI



## Photonics & Sensing

Plasmonic Particle,  
Multiferroic Nanowire,  
Piezoelectric  
Nanowire Assembly



## Biomedical

Lab-on-a-Chip  
Microscale Cell  
Separation



**See us at the EIPBN**  
**poster session**